What is claimed is:

- 1 A glass molding die, comprising:
- 2 a substrate;
- a first noble metal layer overlying the substrate;
- a second noble metal layer overlying the first noble
- 5 metal layer;
- a carbon-containing third noble metal layer overlying
- 7 the second noble metal layer; and
- 8 a DLC (diamond-like carbon) passivation film overlying
- 9 the third noble metal layer.
- 1 2. The molding die as claimed in claim 1, wherein the
- 2 substrate comprises tungsten carbide.
- 1 3. The molding die as claimed in claim 1, wherein the
- 2 first noble metal layer comprises Ni-containing Ir-Re alloy.
- 1 4. The molding die as claimed in claim 1, wherein the
- 2 thickness of first noble metal layer comprises about 0.3 to
- 3 0.6μm.
- 1 5. The molding die as claimed in claim 1, wherein the
- 2 second noble metal layer comprises Ir-Re alloy.
- 1 6. The molding die as claimed in claim 1, wherein the
- 2 thickness of second noble metal layer is about 0.3 to 0.6 µm.
- 1 7. The molding die as claimed in claim 1, wherein the
- 2 thickness of third intermediate layer is about 0.01 to
- 3 0.05µm.

- 1 8. The molding die as claimed in claim 1, wherein the
- 2 third noble metal layer comprises carbon-containing Ir-Re
- 3 alloy with C, Ir, and Re atoms therein approximately
- 4 arranged in superlattice.
- 9. The molding die as claimed in claim 8, wherein
- 2 carbon concentration in the third noble metal layer is
- 3 approximately 20% or more.
- 1 10. The molding die as claimed in claim 1, wherein the
- 2 third noble metal layer comprises carburized Ir-Re alloy.
- 1 11. The molding die as claimed in claim 10, wherein
- 2 carbon concentration in the carburized surface of the third
- 3 noble metal layer is approximately 20% or more.
- 1 12. The molding die as claimed in claim 1, wherein the
- 2 thickness of passivation film is about 0.01 to 0.3μm.
- 1 13. The molding die as claimed in claim 1, wherein the
- 2 passivation film comprises a molding surface.
- 1 14. The molding die as claimed in claim 1, wherein
- 2 when the DLC passivation film deteriorates, the deteriorated
- 3 DLC passivation film and third noble metal layer are removed
- 4 by oxygen plasma, followed by sequential formation of the
- 5 third noble layer and DLC passivation film overlying the
- 6 second noble metal layer.
- 1 15. A renewing method for a glass molding die,
- 2 comprising:

- 3 providing a used glass molding die comprising a 4 substrate, a first noble metal layer overlying 5 the substrate, a second noble metal overlying the first noble layer metal, a carbon-6 7 containing third noble metal layer overlying the second noble metal layer, and a DLC passivation 8 9 film overlying the third noble metal layer; 10 removing the passivation film and third noble metal 11 layer using oxygen plasma; grinding and polishing the molding die to completely 12 13 remove the third noble metal layer; 14 cleaning the polished molding die; 15 forming a fourth noble metal layer overlying the second noble metal layer; and 16 17 forming a second passivation film comprising 18 approximately the same material as the 19 passivation film overlying the fourth noble metal
 - 1 16. The method as claimed in claim 15, wherein the 2 substrate comprises tungsten carbide.

layer.

- 1 17. The method as claimed in claim 1, wherein the 2 first noble metal layer comprises Ni-containing Ir-Re alloy.
- 1 18. The method as claimed in claim 15, wherein the 2 thickness of first noble metal layer comprises about 0.3 to
- 3 0.6μm.

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1 19. The method as claimed in claim 15, wherein the 2 second noble metal layer comprises Ir-Re alloy.

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- 1 20. The method as claimed in claim 15, wherein the
- 2 thickness of second noble metal layer is about 0.3 to 0.6 µm.
- 1 21. The method as claimed in claim 1, wherein the
- 2 thickness of third intermediate layer is about 0.01 to
- 3 0.05μm.
- 1 22. The method as claimed in claim 15, wherein the
- 2 third noble metal layer comprises carbon-containing Ir-Re
- 3 alloy with C, Ir, and Re atoms therein approximately
- 4 arranged as superlattice.
- 1 23. The method as claimed in claim 15, wherein the
- 2 third noble metal layer comprises carburized Ir-Re alloy.
- 1 24. The method as claimed in claim 15, wherein the
- 2 fourth noble metal layer comprises approximately the same
- 3 material as the third noble metal layer.
- 1 25. The method as claimed in claim 15, wherein the
- 2 fourth noble metal layer comprises carbon-containing Ir-Re
- 3 alloy with C, Ir, and Re atoms therein approximately
- 4 arranged as superlattice.
- 1 26. The method as claimed in claim 25, further
- 2 comprising forming the fourth noble metal layer using co-
- 3 sputtering with multiple targets.
- 1 27. The method as claimed in claim 25, wherein carbon
- 2 concentration in the fourth noble metal layer is
- 3 approximately 20% or more.

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- 1 28. The method as claimed in claim 15, wherein the
- 2 fourth noble metal layer comprises carburized Ir-Re alloy.
- 1 29. The method as claimed in claim 28, wherein forming
- 2 the fourth noble metal layer further comprises:
- forming a Ir-Re alloy layer overlying the second noble
- 4 metal layer; and
- 5 implanting carbon ions into a surface of the Ir-Re
- 6 alloy layer, thereby carburizing the Ir-Re alloy
- 7 layer.
- 1 30. The method as claimed in claim 28, wherein carbon
- 2 concentration in the carburized surface of the fourth noble
- 3 metal layer is approximately 20% or more.
- 1 31. The method as claimed in claim 15, wherein the
- 2 thickness of second passivation film is about 0.01 to 0.3µm.
- 1 32. The method as claimed in claim 1, wherein the
- 2 second passivation film has a molding surface.